

Preface; *in memoriam* E. Havinga

The XIII IUPAC Symposium on Photochemistry was held under the Chairmanship of Professor F. Lewis (Northwestern University, Illinois, USA) at the University of Warwick 22-28 July 1990. Once again we were privileged to have lectures given by distinguished photochemists as well as some excellent up-and-coming younger scientists. The major fields of photochemistry were covered by the programme of lectures and well supported by a large number of posters. One of the sessions was devoted to industrial photochemistry and this was backed up by a few industrial presentations.

At the symposium the Porter Medal was presented to Professor M. Kasha (Florida, USA) for his "important recent contributions to photochemistry". There was a very strong field of candidates for the award which gave the adjudicators - the Presidents of the European Photochemical Association, Japanese Photochemical Association and Inter-American Photochemical Society a very difficult time. Professor Kasha brought the symposium to a close with his Porter Medal address included herein.

This issue of Pure and Applied Chemistry (PAC) contains the texts of plenary and invited lectures delivered at the symposium — with the exception of those where manuscripts were not provided or arrived after the deadline. As Editor I do hope that the published material will prove useful to all photochemists and gives some idea as to how this subject is progressing and of some of the exciting developments that lie ahead.

I should like to thank Professor Fred Lewis for his support in acquiring manuscripts and to the Executive Editor of PAC, P.D. Gujral, and his coworkers at the IUPAC Secretariat and Blackwell Scientific Publications for ensuring speedy publication.



Egbert Havinga

Professor Egbert Havinga

I am sure that I echo the feelings of photochemists when I say that photochemistry suffered an enormous loss when Professor Egbert Havinga of Leiden (The Netherlands) passed away on 22nd November 1988. Professor Havinga not only made many seminal contributions to the subject, but also inspired a host of younger colleagues and was a regular active participant in the IUPAC photochemistry meetings. He will be sadly missed and our sincere condolences are conveyed to Mrs. Louise Havinga who so frequently accompanied her husband at these meetings.

R.S. Davidson
Symposium Editor